

Catalytic Si–C bond formation by nucleophilic substitution at silicon by benzyl anions generated over KNH₂ loaded on alumina

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The catalytic substitution at silicon occurs in the reaction of toluene and diethylsilane in the presence of KNH₂ loaded on alumina, the yield of benzyldiethylsilane being 85% in 40 h at 329 K. Benzene also reacted with diethylsilane in the presence of the catalyst to afford a 7.5% yield of benzyl diethylsilane in 20 h at 329 K.

Keywords: solid base, KNH₂ loaded on alumina, Si–C bond formation, toluene, diethylsilane

1. Introduction

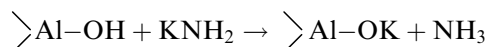
The nucleophilic substitution by a carbanion at silicon is a most conventional method for Si–C bond formation [1–5]. The substitution proceeds through penta- or hexa-coordinated silicon intermediates. Various methods for activating Si–X (X: leaving group) are also discussed. The most common sources of carbanions are alkyl-lithium or Grignard reagents, but the reactions are not catalytic.

Carbanions can be generated on solid surfaces. Ito et al. reported that dehydrogenative coupling occurs between phenylsilanes and monosubstituted acetylenes RC≡CH over MgO or CaO [6], which is known as a strongly basic solid. Thus, the reaction of diphenylsilane and 1-hexyne (C₄H₉C≡CH) proceeds in the presence of MgO to give a 52% yield of 1-diphenylsilyl-1-hexyne. The reaction mechanism seems to involve C₄H₉C≡C[–] anions as intermediates, which are formed by the abstraction of H⁺ by the basic sites of the catalyst.

We have reported that KNH₂, which was loaded on Al₂O₃ from the ammoniacal solution followed by heating under vacuum at 573 K, is a super-base [7]. The material is denoted as KNH₂/Al₂O₃ hereinafter. KNH₂/Al₂O₃ shows very high catalytic activities for the isomerization of various alkenes [7] and olefinic amines [8], which proceeds through carbanion intermediates. For example, 2,3-dimethylbut-1-ene is readily isomerized to 2,3-dimethylbut-2-ene, even at 210 K. Moreover, the reaction of phenylacetylene over KNH₂/Al₂O₃ results in its dimerization to afford (Z)- and (E)-1,4-diphenyl-1-ene-3-yne, the ratio of (Z) and (E) being 94 : 3 [9].

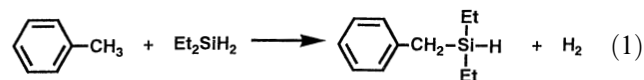
We have also reported IR spectra of KNH₂/Al₂O₃ and the effect of the amount of KNH₂ supported on Al₂O₃ on the catalytic activity for the isomerization of 2,3-dimethylbut-1-ene to 2,3-dimethylbut-2-ene [7].

Thus, the OH groups on the surface of Al₂O₃ react with KNH₂ as follows:



The >Al–OK does not show catalytic activity, while KNH₂ loaded on alumina acts as a catalyst.

Because of the very strong basicity of KNH₂/Al₂O₃, the catalyst is expected to activate toluene, of which the pK_a value is 35 [10]. Here, we report that the dehydrogenative coupling of toluene and diethylsilane is catalyzed by KNH₂/Al₂O₃.



2. Experimental

γ-alumina used as a support has a surface area of 135 m² g^{–1}. MNH₂/Al₂O₃ (M: Na, K, Rb) was prepared from an ammoniacal solution of the alkali metal by an impregnation method. The preparation of the catalyst and the catalytic reaction were carried out in the same quartz tube, which could be attached to a high-vacuum system. Alumina was heated in a quartz tube at 673 K for 3 h. A piece of K (Na or Rb) metal was then placed in the quartz tube under nitrogen with a small amount of Fe₂O₃. After evacuation of the system at room temperature, ammonia was liquefied in the quartz tube at dry ice–ethanol temperature to dissolve the metal. A blue color due to the solvated electrons developed. The color gradually faded and disappeared, indicating the transformation of the metal to the corresponding amide. Added Fe₂O₃ serves as a catalyst for the transformation. The solution was kept in contact with alumina for 1 h, and then heated under vacuum for 3 h at prescribed tem-

Table 1
Catalytic activities of various solid bases^a

Catalyst	Amount of metal (mmol/1.00 g of Al ₂ O ₃)	Yield of benzyl-diethylsilane (%)
KNH ₂ /Al ₂ O ₃	2.6	74 85 ^b 64 ^c
RbNH ₂ /Al ₂ O ₃	2.6	73
NaNH ₂ /Al ₂ O ₃	2.6	0
KF/Al ₂ O ₃	5.0	2
MgO		0
CaO		0

^a Catalyst weight: 0.20 g, reaction temperature: 329 K, reaction time: 20 h, Et₂SiH₂: 1.5 mmol, toluene: 28 mmol.

^b Reaction time: 40 h.

^c Reaction temperature: 303 K.

temperatures, which are 523, 573, and 623 K for NaNH₂/Al₂O₃, KNH₂/Al₂O₃, and RbNH₂/Al₂O₃, respectively, since the catalysts evacuated at these temperatures showed the highest catalytic activities for the isomerization of 2,3-dimethylbut-1-ene.

CaO and MgO were prepared by heating CaCO₃ at 998 K and Mg(OH)₂ at 773 K, respectively, under vacuum. KF supported on alumina (KF/Al₂O₃) was prepared by heating alumina loaded with KF under vacuum at 673 K. The loading of KF was done with an impregnation method from its aqueous solution.

The mixture of the purified reactants was put into a glass tube, which was then attached to the side arm of the reactor, and degassed with a freeze–thaw method. The reaction was started by transferring the reactants into the reactor.

The products were identified by ¹H NMR (270 MHz) and GC-mass spectroscopy. The amount of the products were determined by a gas chromatograph equipped with an OV 101 glass column, using propylbenzene as an internal standard. The yields of products were calculated based on the starting silanes.

3. Results and discussion

When Et₂SiH₂ (1.5 mmol, 0.20 cm³) was stirred with 0.2 g of KNH₂/Al₂O₃ in excess toluene (28 mmol, 2.0 cm³) at 329 K for 20 h, benzyl-diethylsilane¹ was obtained in a 74% yield (table 1). The molar ratio of the formed benzyl-diethylsilane to the amount of KNH₂ supported on Al₂O₃ was 2.1, indicating the reaction is catalytic. The yield increased by increasing the reaction

¹ Benzyl-diethylsilane: ¹H NMR (CDCl₃) 0.60 (4H, dq, *J* = 3.3, 7.9, –SiCH₂), 0.96 (6H, t, *J* = 7.6, CH₃), 2.18 (2H, d, *J* = 3.3, –SiCH₂C₆H₅), 3.76 (1H, t, quint, *J* = 3.3, 3.3, –SiH), 7.00–7.22 (5H, m, –C₆H₅). MS(*m/e*) 178(41), 149(49), 121(98), 87(100), 59(92).

Table 2
Reactivities of alkylbenzenes with Et₂SiH₂ over KNH₂/Al₂O₃^a

Reactant	pK _a	Amount of reactant (mmol)	Yield (%)
toluene	35 ^b	28	74
ethylbenzene		25	23
propylbenzene		21	7.0
isopropylbenzene	37 ^c	29	2.0

^a Catalyst weight: 0.20 g, reaction temperature: 329 K, reaction time: 20 h, Et₂SiH₂: 1.5 mmol. Amount of K metal 2.6 mmol per 1.00 g of Al₂O₃.

^b Ref. [10].

time to 40 h. The yield was lower at lower temperature, being 64% at 303 K in 20 h. Other reactions such as disproportionation of Et₂SiH₂ were not observed. RbNH₂/Al₂O₃ was as active as KNH₂/Al₂O₃ for the dehydrogenative coupling. For this reaction, KF/Al₂O₃ showed a very low activity, while NaNH₂/Al₂O₃, CaO and MgO were totally inactive.

Reaction of Et₂SiH₂ with other alkylbenzenes such as ethylbenzene also proceeded in the presence of KNH₂/Al₂O₃ to selectively afford the corresponding benzylsilanes, as shown in table 2. Ethylbenzene gave a 23% yield of diethyl-1-phenylethylsilane². Propylbenzene and isopropylbenzene reacted with Et₂SiH₂ to give diethyl(1-phenylpropyl)silane³ and diethyl(1-phenyl-1-methylethyl)silane⁴ in 7 and 2% yield, respectively. As shown in table 2, alkylbenzene with more acidic protons showed higher reactivity towards Et₂SiH₂, indicating that the abstraction of a proton from alkylbenzene by basic sites on the solid base is the rate-determining step. The reactions proceed through carbanion intermediates, which cause nucleophilic substitution at silicon.

Toluene (28 mmol) also reacted with Et₂SiH (3.2 mmol) in the presence of KNH₂/Al₂O₃ (0.2 g) to afford a 32% yield of benzyltriethylsilane⁵ in 20 h at 363 K. The reaction of toluene (28 mmol) with phenylsilane (4.2 mmol) gave only 1% yield in 20 h at 373 K. In this case, the disproportionation of phenylsilane was accompanied.

Benzene has a pK_a value of 37 comparable to propylbenzenes [10] and therefore is expected to undergo the similar reaction. When Et₂SiH₂ (3.1 mmol, 0.4 cm³) was stirred with 1.0 g of KNH₂/Al₂O₃ in benzene (68 mmol,

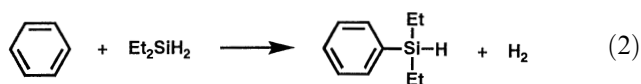
² Diethyl-1-phenylethylsilane: ¹H NMR (CDCl₃) 0.49 (2H, dq, *J* = 3.0, 7.6, –SiCH₂), 0.58 (2H, dq, *J* = 3.0, 7.6, –SiCH₂), 0.88 (3H, t, *J* = 7.9, –CH₃), 0.96 (3H, t, *J* = 7.9, CH₃), 2.35 (1H, dq, *J* = 3.3, 7.4, –SiCH), 3.64 (1H, d, quint, *J* = 3.0, 3.0, –SiH), 7.09–7.28 (5H, m, C₆H₅). MS(*m/e*) 164(22), 153(56), 107(100), 86(18).

³ Diethyl(1-phenylpropyl)silane: MS(*m/e*) 206(17), 177(9), 149(9), 135(6), 118(100), 105(13), 87(61), 59(67).

⁴ Diethyl (1-phenyl-1-methylethyl)silane: MS(*m/e*) 206(21), 118(100), 87(50), 59(50).

⁵ Benzyltriethylsilane: MS(*m/e*) 206(22), 177(7), 149(21), 115(100), 87(99), 59(33).

6 cm³), diethylphenylsilane⁶ was obtained in a 7.5% yield in 20 h at 329 K.



In conclusion, strongly basic catalysts such as KNH₂/Al₂O₃ offer a novel route to form Si–C bonds directly from alkylbenzenes and silanes.

⁶ Diethylphenylsilane: ¹H NMR (CDCl₃) 0.86 (4H, dq, *J* = 3.3, 7.9, –SiCH₂), 1.00 (6H, t, *J* = 7.9, –CH₃), 4.20 (1H, quint, *J* = 3.3, –SiH), 7.34–7.37 and 7.51–7.55 (5H, m, C₆H₅). MS(*m/e*) 164(22), 153(56), 107(100), 86(18).

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